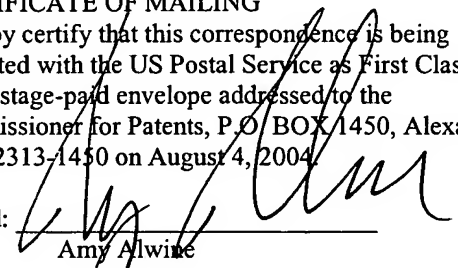




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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of: Basol Serial No.: 10/772,687 Filed: February 5, 2004 Title: PROCESS AND SYSTEM FOR PROVIDING ELECTROCHEMICAL PROCESSING SOLUTION WITH REDUCED OXYGEN AND GAS CONTENT	Group Art Unit: 1753 Examiner: Not yet assigned Docket: NT-319-US CERTIFICATE OF MAILING I hereby certify that this correspondence is being deposited with the US Postal Service as First Class Mail in a postage-paid envelope addressed to the Commissioner for Patents, P.O. BOX 1450, Alexandria, VA 22313-1450 on August 4, 2004. Signed:  Amy Alwine
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INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents
P.O. BOX 1450
Alexandria, VA 22313-1450

Dear Sir:

Applicants submit information herewith to comply with the obligations set forth in 37 CFR §1.56. This submission is not an admission that any of the documents are prior art or otherwise relevant to the subject application.

This IDS is submitted:

- ☐ with a filed patent application or within 3 months of the US application filing date;
☒ before the mailing of a first office action on the merits;
☐ after the first office action, but prior to a final rejection or notice of allowance, and is accompanied by the fee set forth in 37 CFR §1.17(p) or a certification set forth below; or
☐ after a final rejection or notice of allowance, and is accompanied by the fee set forth in 37 CFR §1.17(p) and a certification set forth below, where this submission is a petition requesting consideration of this IDS.

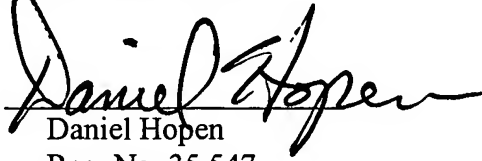
If identified above, Applicant certifies that:

- ☐ the information was first cited in a communication from a foreign patent office in a counterpart foreign application less than 3 months prior to this IDS; or

[] to the knowledge of the person signing this certification after making reasonable inquiry, the information was not known to any individuals designated in 37 CFR §1.56 more than 3 months prior to this IDS.

If any matters can be resolved by telephone, Applicant requests that the Patent and Trademark Office call the Applicant at the telephone number listed below.

Respectfully submitted,

By: 
Daniel Hopen
Reg. No. 35,547

NuTool, Inc.
Legal Department
1655 McCandless Drive
Milpitas, CA 95035
(408) 586-9500x268



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of: Basol Serial No.: 10/772,687 Filed: February 5, 2004 Title: PROCESS AND SYSTEM FOR PROVIDING ELECTROCHEMICAL PROCESSING SOLUTION WITH REDUCED OXYGEN AND GAS CONTENT	Group Art Unit: 1753 Examiner: Not yet assigned Docket: NT-319-US
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INFORMATION DISCLOSURE STATEMENT

US PATENT DOCUMENTS

Examiner Initials	Cite No.	Document Number	Publication Date	Name of Patentee or Applicant	
	AA	6,113,769	Sep., 2000	Uzoh et al.	In Serial No. 10/425,782

FOREIGN PATENT DOCUMENTS

Examiner Initials	Cite No.	Document Number	Publication Date	Name of Patentee or Applicant		

OTHER DOCUMENTS

Examiner Initials	Cite No.			Trans-lation
	AB	Victoria Shannon et al., "Copper Interconnects for High-Volume Manufacturing", Semiconductor International, May 2001	In Serial No. 10/425,782	

Examiner Signature		Date Considered	
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